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INFORMATION DISCLOSURE CITATION

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Applicant: Joachim MAI, et al.

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U.S. PATENT DOCUMENTS

Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
		US-					

FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
/RM/	F1	DE- 4108404	10/10/1991	DE				N*
/RM/	F2	DE- 39724	1/23/1964	DE				N ^P

TRANSLATION KEY: * English Abstract. ^F Concise statement of relevance provided in foreign search report. ^C Concise statement of relevance provided in specification or in attachment to document. ^S Concise statement of relevance provided in IDS. ^P Relevant portion of document translated. ^O English abstract only - copy of document in pct search.

OTHER INFORMATION DISCLOSURE CITATIONS (Including Author, Title, Date, Pertinent Pages, Etc.)

/RM/	01	5/21/2003 "Reactive etching of semiconductor surfaces using an electronically chopped low energy broad beam ion source" J. Dienelt et al. Elsevier Science B.V., Surface and Coatings Technology Volumes 174-175 Pages 157-161
/RM/	02	7/17/2003 "Generation of a pulsed ion beam with a tuned electronic beam switch" J. Dienelt et al. Plasma Sources Science and Technology Vol. 12 Pages 489-494
EXAMINER	/Rodney McDonald/	DATE CONSIDERED 09/02/2010

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